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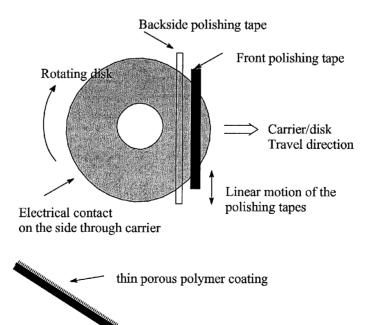
- as to applicant's entitlement to apply for and be granted a patent (Rule 4.17(ii))
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(54) Title: METHOD AND APPARATUS FOR ELECTROCHEMICAL MECHANICAL POLISHING NIP SUBSTRATES



(57) Abstract: The present invention relates to an apparatus and a method of electrochemical mechanical polishing (ECMP) for microelectronics applications. The apparatus and method of electrochemical mechanical polishing can be used planarize NiP substrate for a magnetic storage medium and for a process which allows polishing with a controlled surface finish, and a set of corresponding polishing electrolytes and slurry.

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B. FIELDS SEARCHED			
	ocumentation searched (classification system followed by B 1/00 (2008.04) /57	classification symbols)	
Documentat	ion searched other than minimum documentation to the ex	tent that such documents are included in the	fields searched
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C. DOCU	MENTS CONSIDERED TO BE RELEVANT		
Category*	· Citation of document, with indication, where ap	ppropriate, of the relevant passages	Relevant to claim No.
Y	US 6,957,511 B1 (LEIGH et al) 25 October 2005 (25.	10.2005) entire document	1-3, 5-14
Υ	US 6,811,467 B1 (BERESFORD et al) 02 November 2004 (02.11.2004) entire document		1, 5, 7-14
Υ	US 6,250,995 B1 (HAKOMORI) 26 June 2001 (26.06.2001) entire document		2, 3, 6, 11-14
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